



**HAL**  
open science

## **A simple process for the fabrication of parallel-plate electrostatic MEMS resonators by gold thermocompression bonding**

Maria Dolores Manrique-Juarez, Fabrice Mathieu, Guillaume Libaude, Véronique Conédéra, David Bourrier, Samuel Charlot, Thierry Leichle, Laurent Mazon, Ludovic Salvagnac, Isabelle Dufour, et al.

### ► To cite this version:

Maria Dolores Manrique-Juarez, Fabrice Mathieu, Guillaume Libaude, Véronique Conédéra, David Bourrier, et al.. A simple process for the fabrication of parallel-plate electrostatic MEMS resonators by gold thermocompression bonding. The 36th International Conference on Micro Electro Mechanical Systems (IEEE MEMS 2023), Jan 2023, Munich, Germany. 10.1109/MEMS49605.2023.10052563 . hal-03951363

**HAL Id: hal-03951363**

**<https://laas.hal.science/hal-03951363v1>**

Submitted on 6 Mar 2023

**HAL** is a multi-disciplinary open access archive for the deposit and dissemination of scientific research documents, whether they are published or not. The documents may come from teaching and research institutions in France or abroad, or from public or private research centers.

L'archive ouverte pluridisciplinaire **HAL**, est destinée au dépôt et à la diffusion de documents scientifiques de niveau recherche, publiés ou non, émanant des établissements d'enseignement et de recherche français ou étrangers, des laboratoires publics ou privés.

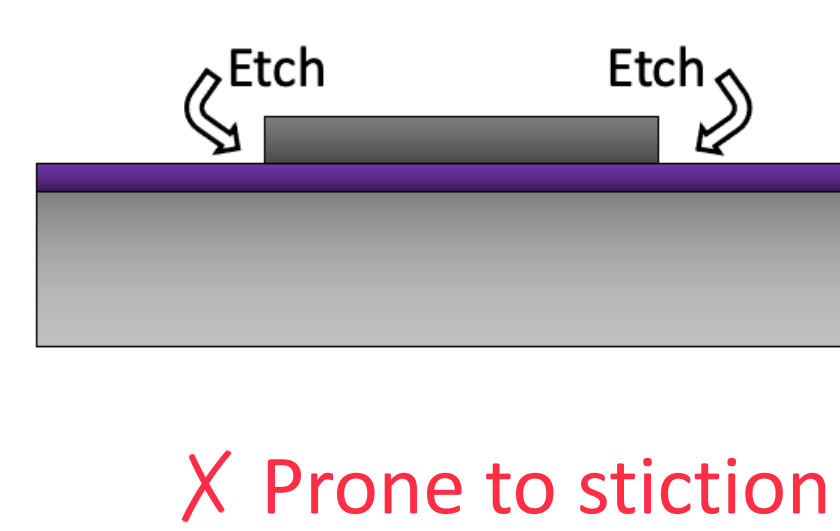
### Novelty / Progress Claim:

We use gold thermocompression bonding to fabricate electrostatic MEMS with the following advantages/characteristics:

- The process is simple and short
- It is suited to the fabrication of flexural mechanical resonators with electrostatic actuation and capacitive detection
- **Mechanical and electrical connections of the free-standing structure are realized in a single step**
- **A sealing joint protects the structure during the wet etching release step**
- **The gap of the parallel-plate capacitor can be easily controlled**  $\Rightarrow$  squeeze-film damping is reduced by fabricating devices with increasing gaps

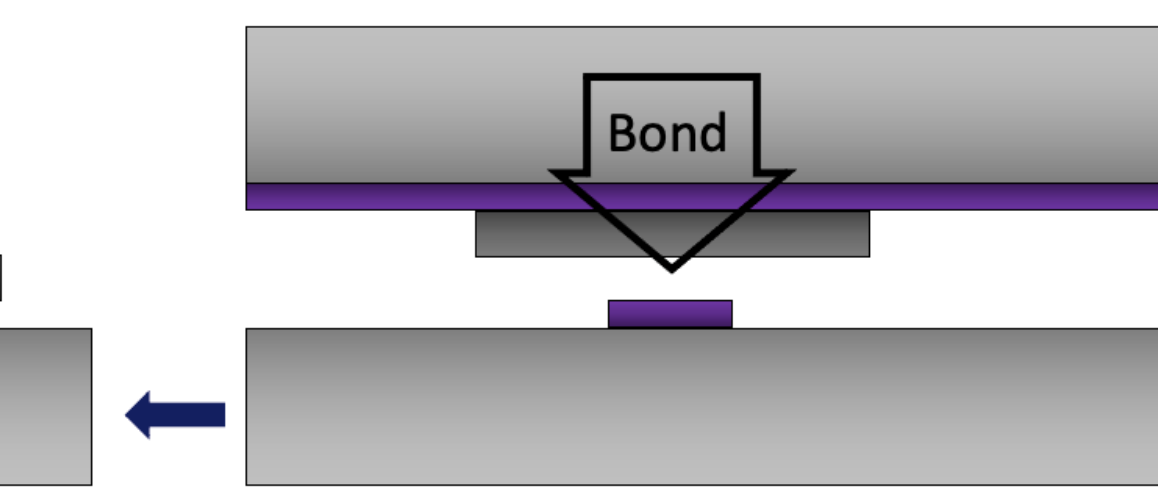
### State of the art: 2 routes to electrostatic MEMS

1. Surface micromachining using a sacrificial layer



X Prone to stiction

2. Transfer methods e.g. wafer bonding, micro-masonry

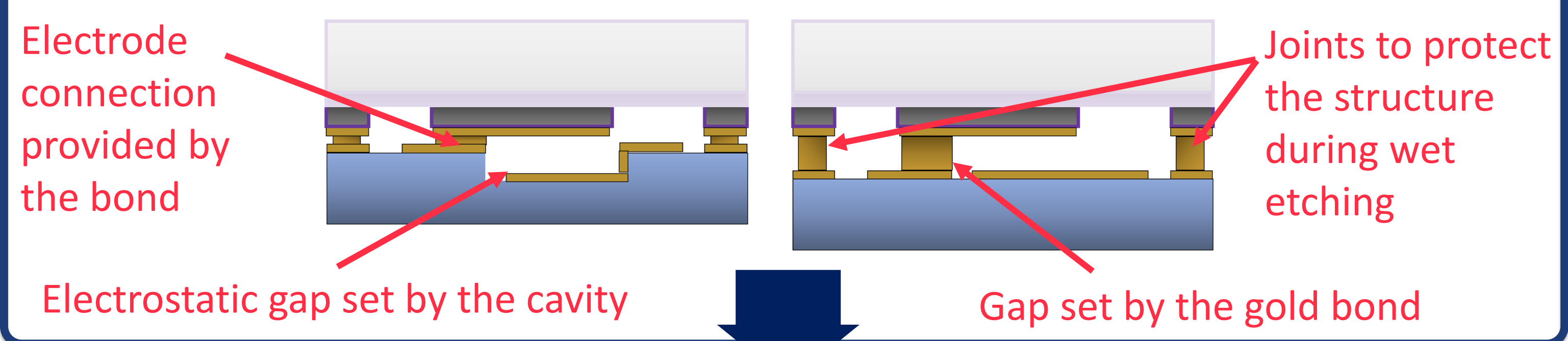


X Difficult electrode integration

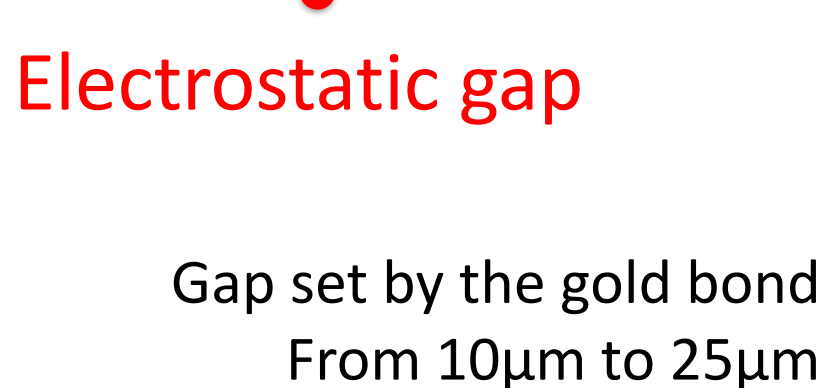
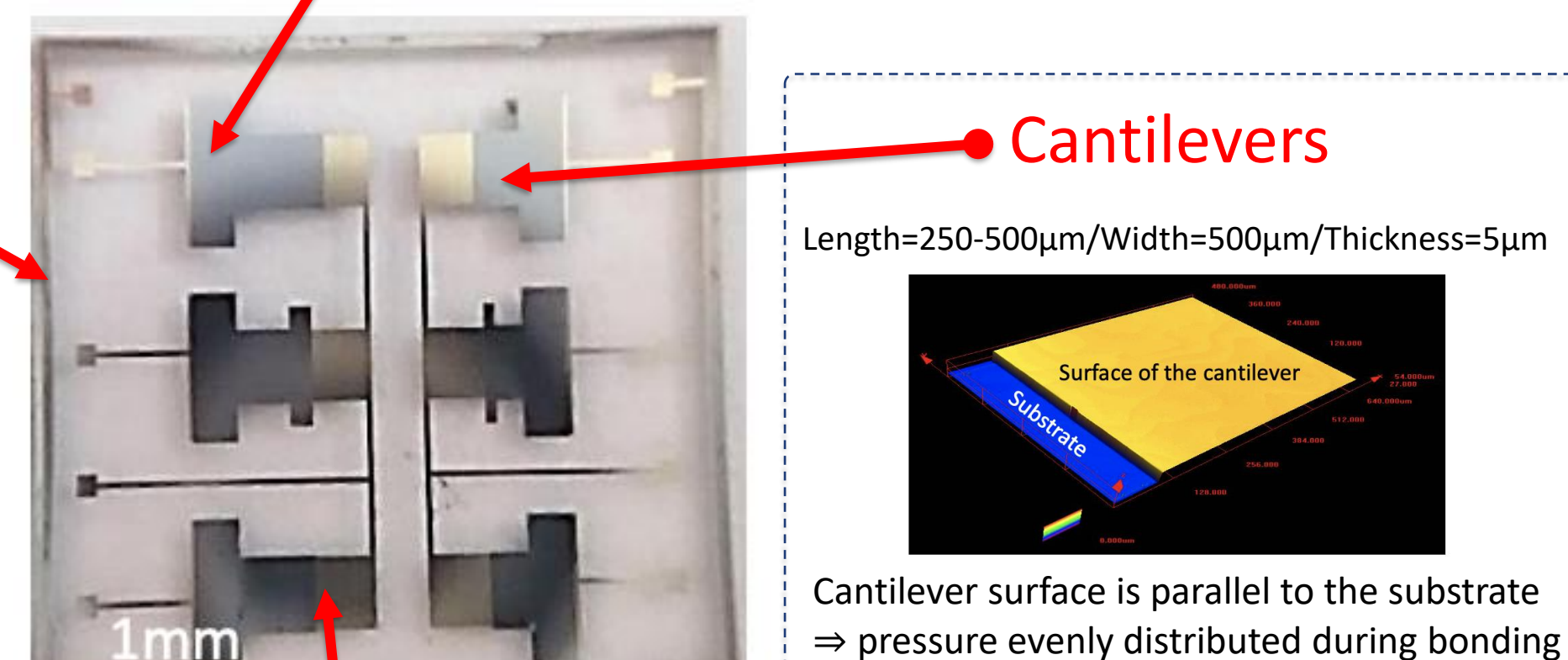
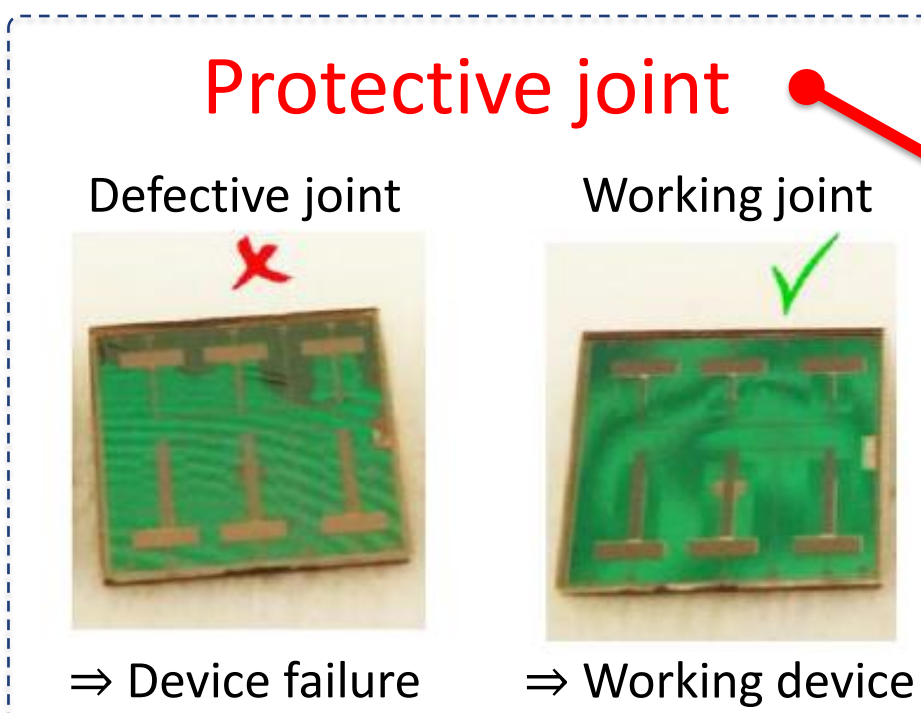
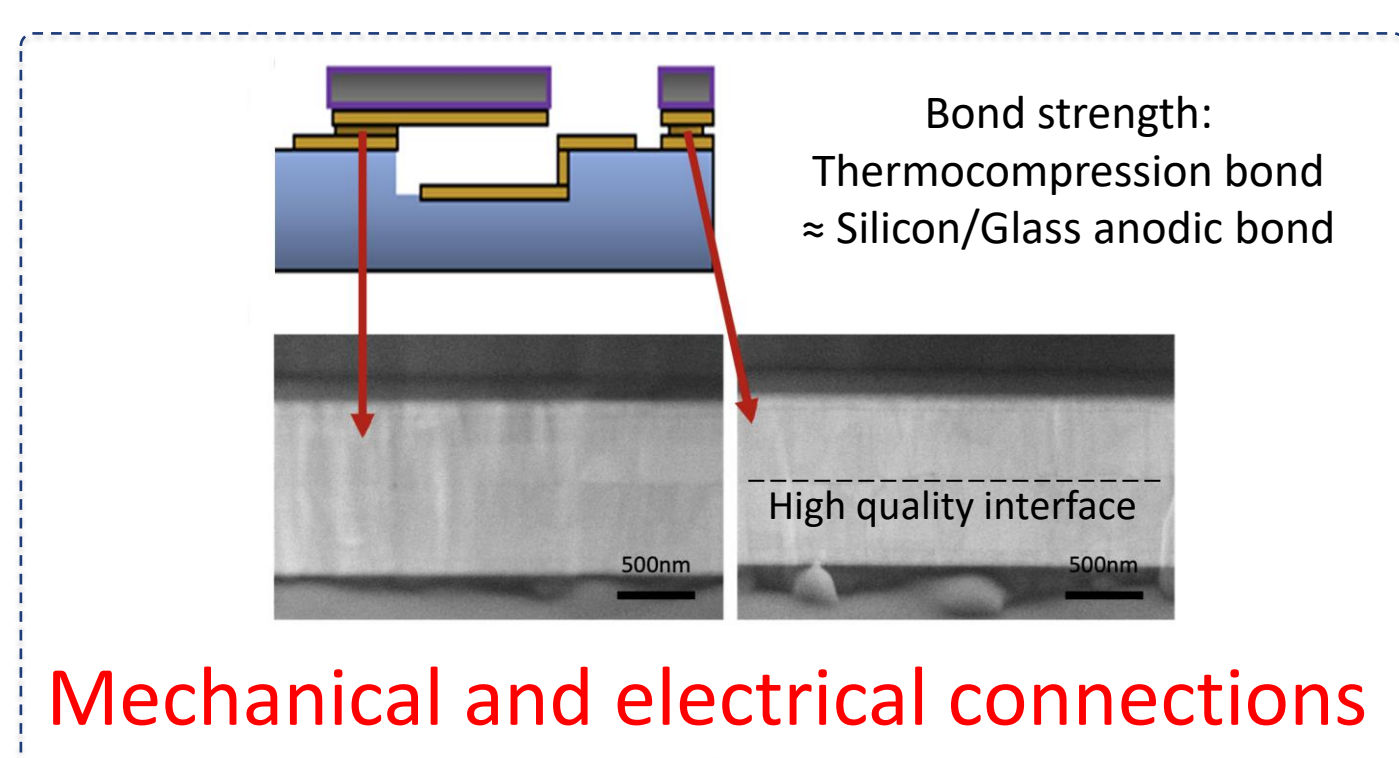
### Our approach

Gold-gold thermocompression bonding is widely used in MEMS packaging  
**Proposition: use thermocompression bonding to fabricate electrostatic MEMS**

2 gap configurations

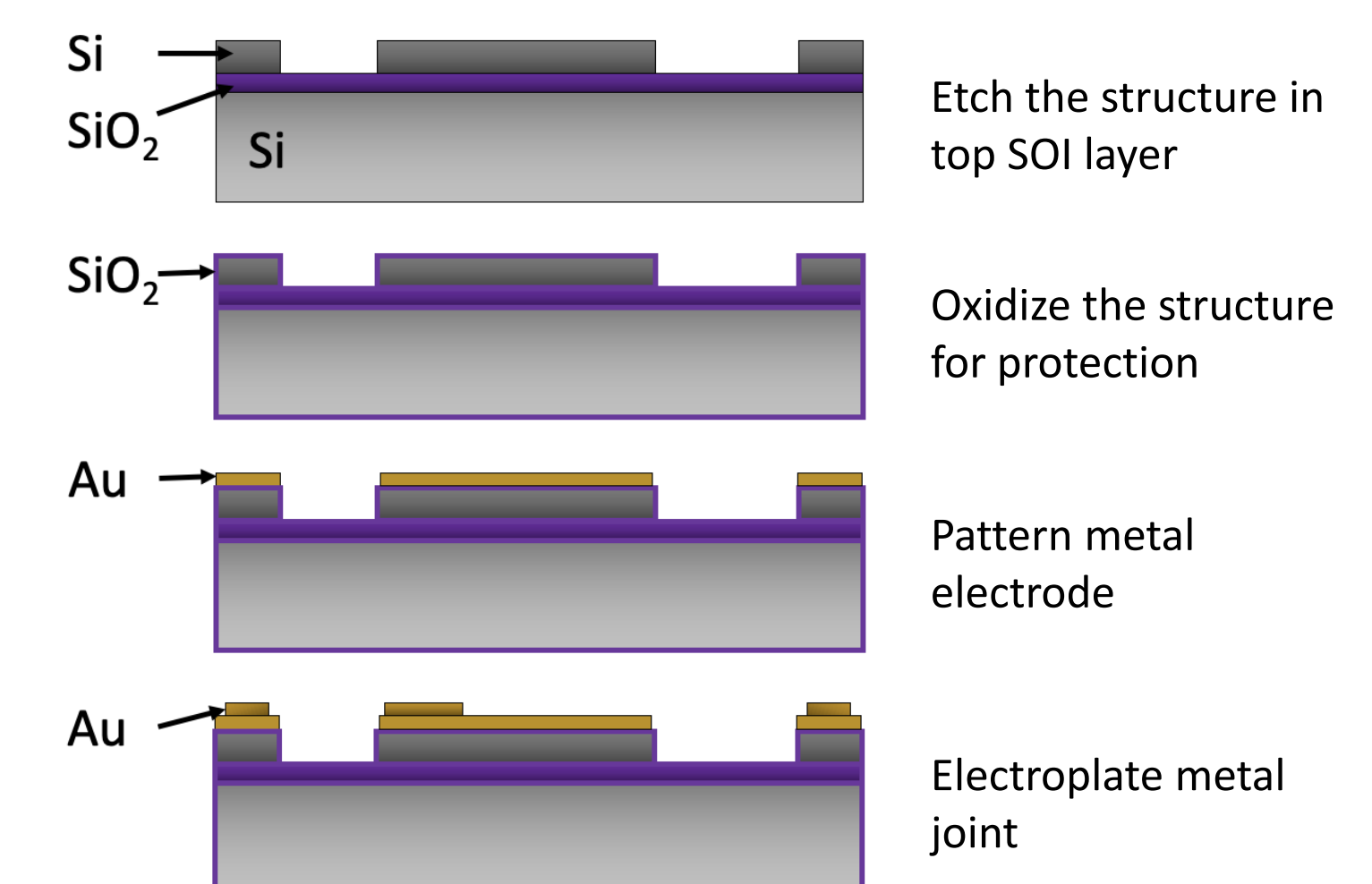


### Fabricated devices

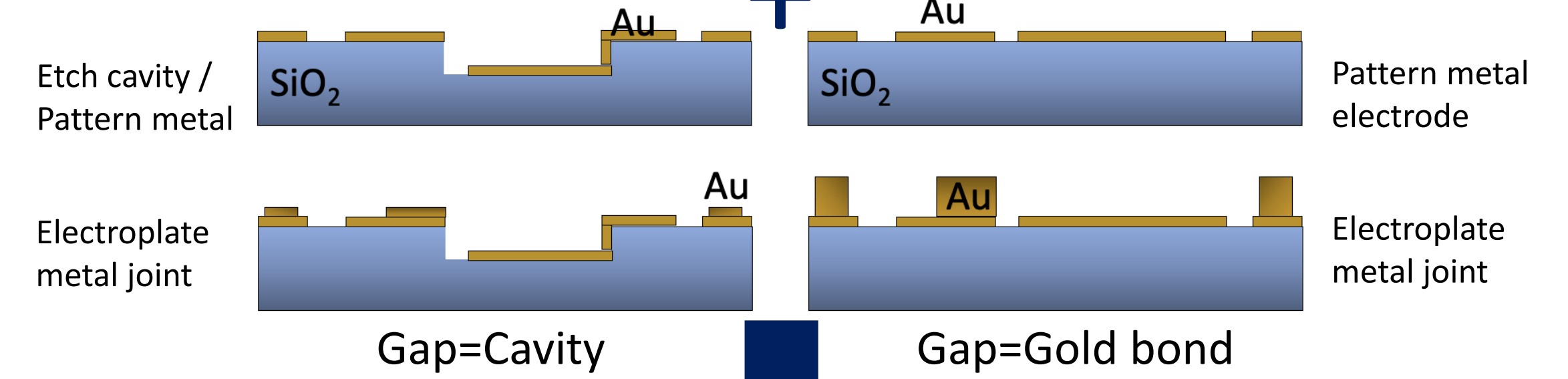


### Fabrication process

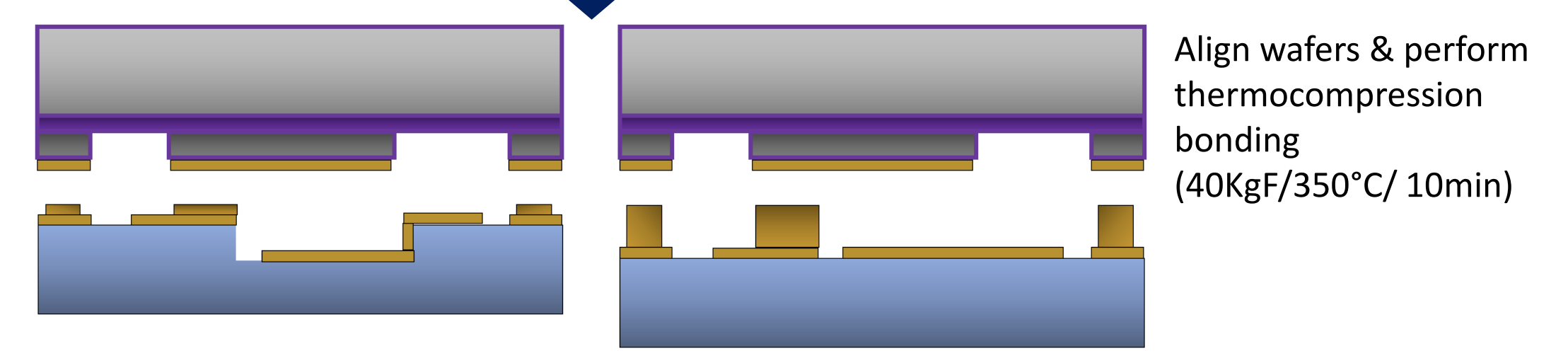
1. Device processing



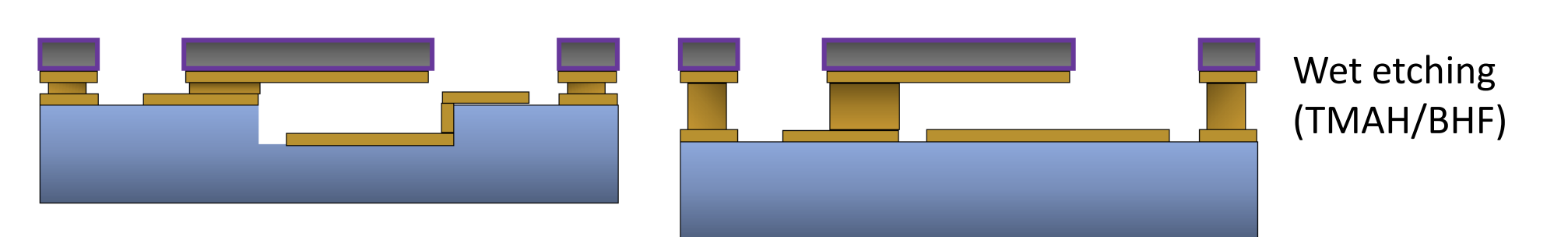
2. Substrate processing



3. Bonding

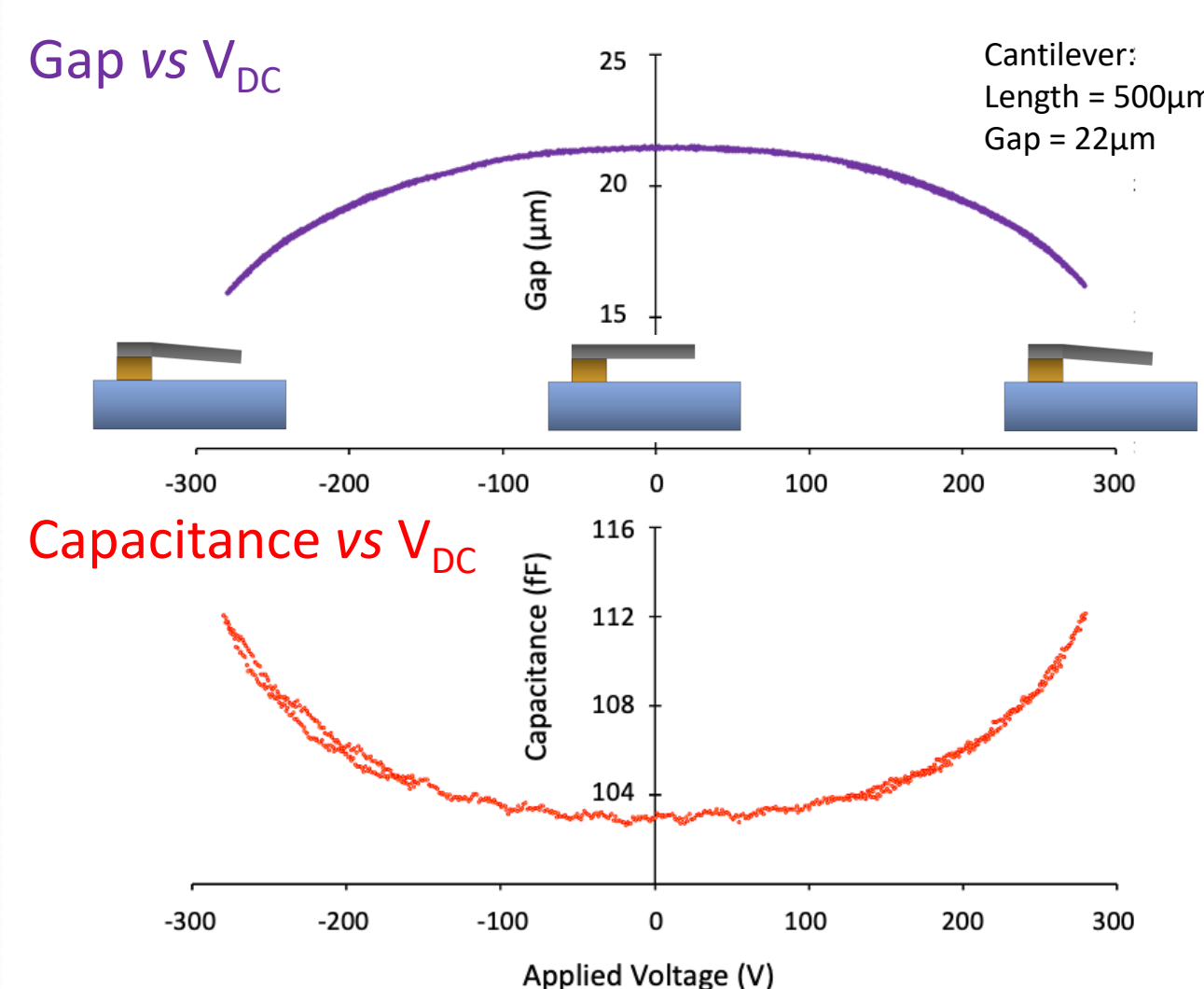


4. Release

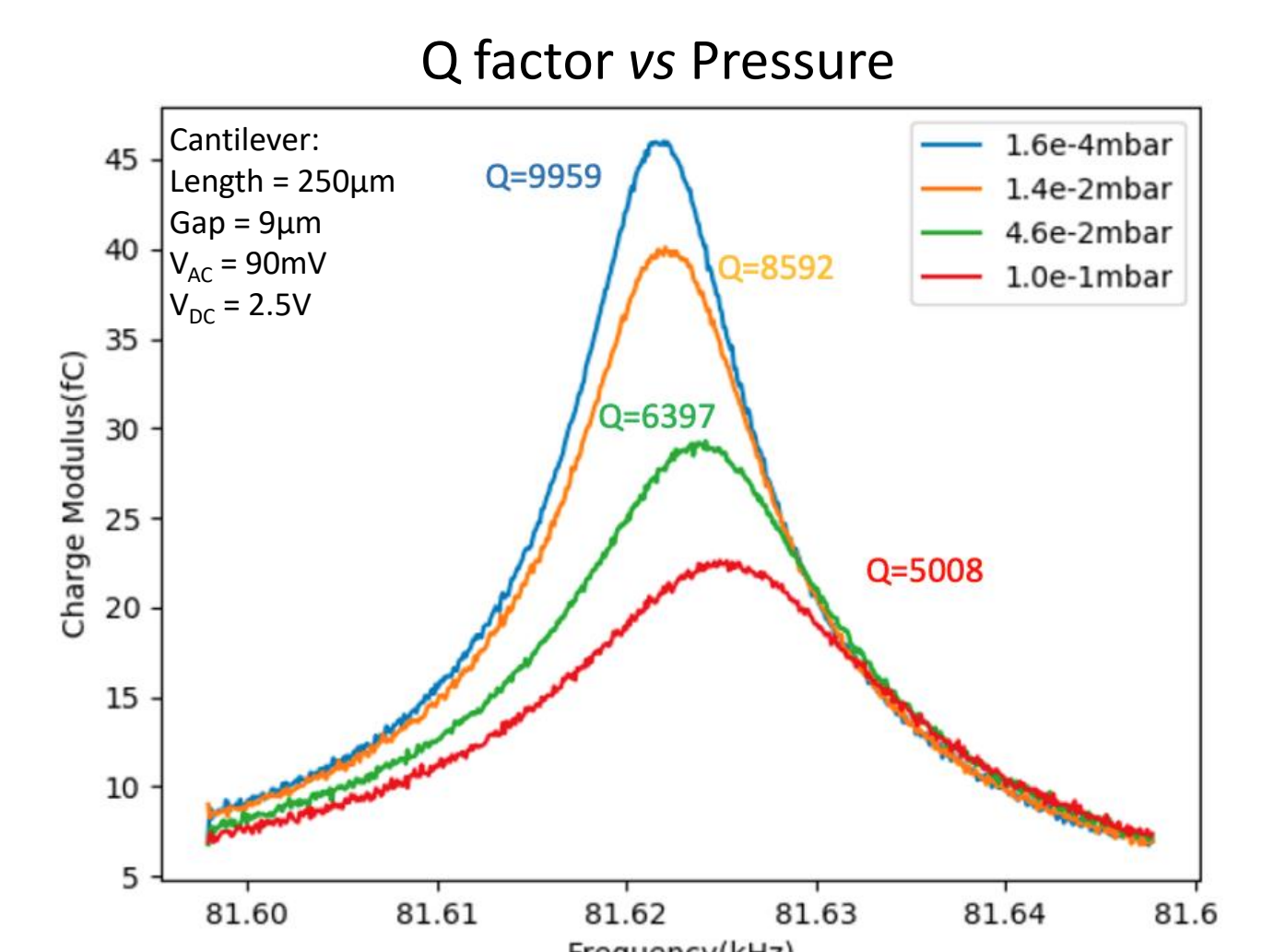
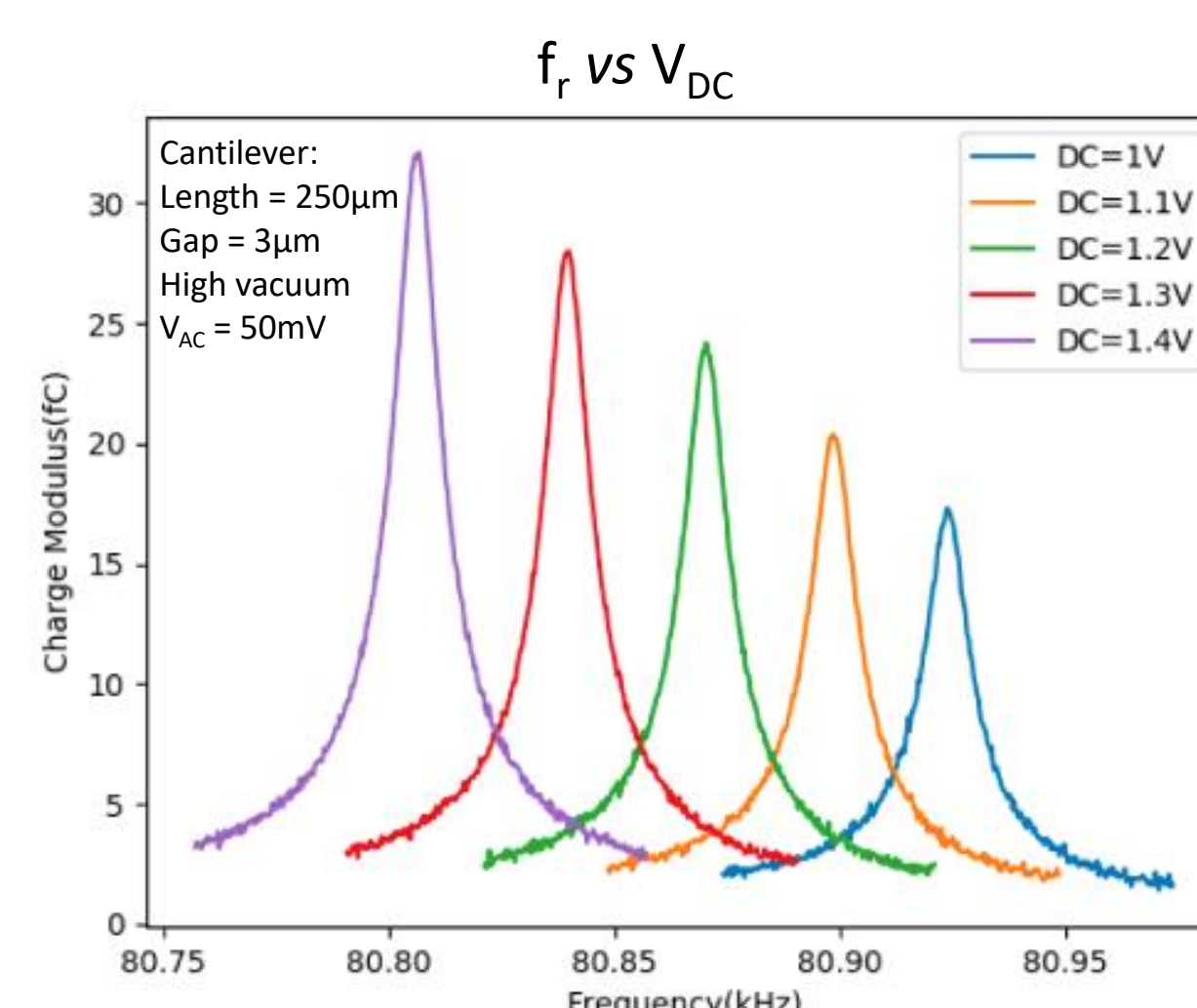
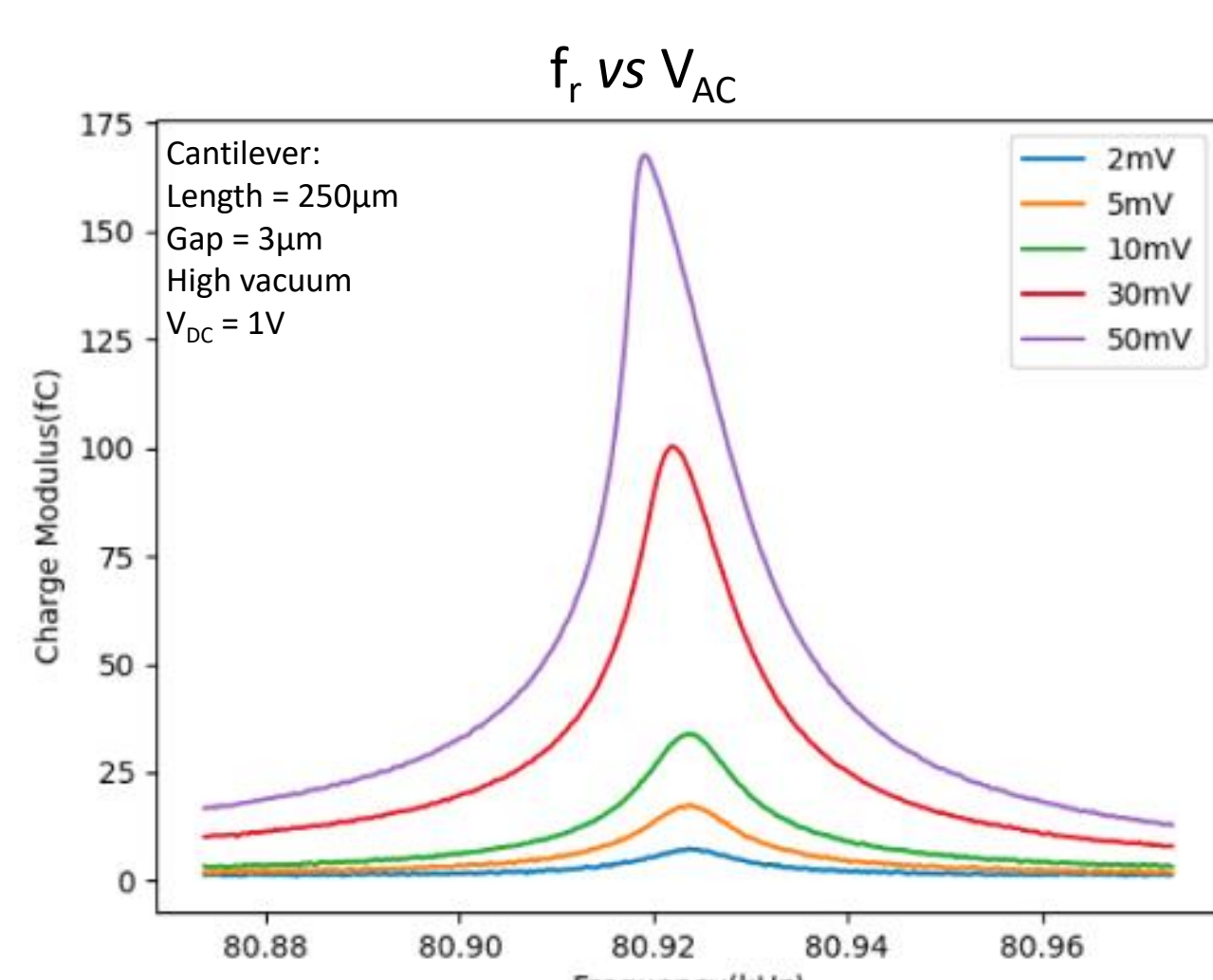


### Characterizations

#### Static mode



#### Dynamic mode



**Conclusions:**

- Gold thermocompression bonding provides mechanical and electrical connections for electrostatic MEMS in a single step
- Fabricated structures behave as theoretically predicted with limited mechanical dissipation due to the gold anchor
- Squeeze-film damping is reduced with thicker thermocompression bonds: critically damped vibrations for 3 $\mu$ m gap in air  $\Rightarrow$  Q = 45 for 25 $\mu$ m gap